PATENTS ORDINANCE (Chapter 514)

NOTICE OF SPECIFICATION OF FORMS

Pursuant to section 150 of the Patents Ordinance (Chapter 514) (the "Ordinance") and section 2(2)(c) of the Patents (General) Rules (Chapter 514C) (the "Rules"), notice is hereby given that the forms specified below and attached to this notice shall, with effect from 1 October 2025, be used in connection with the following proceedings:

Description of Proceedings	Form no.	Fee no.
Filing notice of intention to oppose under section 49(4) of the Ordinance and section 41AA(1) of the Rules	<u>P2</u>	-
Filing notice of opposition under section 149(2A) of the Ordinance and section 31ZW or 73 of and paragraph 2D(1) and (2)(a) of Schedule 1 to the Rules	<u>P2</u>	-
Filing notice of opposition under section 48(2), 49(4) or 146(2) of the Ordinance and section 40(2) and (3)(a), 41AAB(1), 41AAC(1) or 48(4) and (5) of the Rules	<u>P2</u>	2
Filing notice of opposition under section 46(3) or 127E(2) of the Ordinance and section 38B(1) and (3)(a) or 81Q(1) and (3)(a) of the Rules	<u>P2</u>	40
Filing counter-statement under section 9F(1) or (2), 13(6A), 14(5), 37H(1), 37K(7) or 44(4) of the Ordinance and section 2C(1) and (3)(a), 3(7), 7(3) and (4)(a), 31G(1) and (3)(a), 31L(1) and (3)(a), 37(5), 40(4) or 48(6A) of the Rules	<u>P2</u>	2
Filing counter-statement under section 38C(1) and (3)(a) or 81R(1) and (3)(a) of the Rules	<u>P2</u>	41
Request for grant of a short-term patent under section 113, 116 or 125 of the Ordinance and section 58 or 74 of the Rules	<u>P6</u>	6, 8, 10
Request for grant of a standard patent (O) under section 37L or 37Z of the Ordinance and section 31M or 31ZS of the Rules	<u>OP1</u>	33, 34, 35

During the transitional period from 1 October 2025 to 1 January 2026 (the "Transitional Period"), Forms P2, P6 and OP1 as specified in the Notice of Specification of Forms published in the Hong Kong Intellectual Property Journal on 12 May 2025 (the "<u>Previous Notice</u>") may continue to be used in connection with the relevant proceedings except the following:

Description of Proceedings

Filing notice of intention to oppose under section 49(4) of the Ordinance and section 41AA(1) of the Rules

Filing notice of opposition under section 49(4) of the Ordinance and section 41AAB(1) or 41AAC(1) of the Rules

Request for grant of a short-term patent in compliance with an order under section 55(4) of the Ordinance

Request for grant of a standard patent (O) in compliance with an order under section 55(4) of the Ordinance

Upon the expiry of the Transitional Period, this notice shall supersede the Previous Notice (only to the extent applicable to Forms P2, P6 and OP1).

5 September 2025

David WONG Registrar of Patents

香港特別行政區政府知識產權署 nt of the Hong Kong Special Administrative Region Intellectual Property Department

	P2-
For official use	

Patents Form P2

Filing of notice of intention to oppose, notice of opposition or counter-statement

Patents Ordinance (Cap. 514) Patents (General) Rules (Cap. 514C)

Important notes

1. General notes:

- Please complete this form in English unless otherwise stated. a.
- By submitting this form, you will be treated as having given consent to the Patents Registry and its service provider to copy or communicate all the information provided to any third party (in or outside Hong Kong, China) who assists or supports the Patents Registry in performing its functions under the Patents Ordinance, Cap. 514 and its subsidiary legislation.
- This form must be signed and dated.
- d. If there is not enough space for any part on this form, please continue on an additional sheet. Number each additional sheet and state the number of additional sheet(s).
- Please enquire through the following means:
 - E-mail: enquiry@ipd.gov.hk
 - Internet homepage address: www.ipd.gov.hk

2. Use of personal data:

- a. Personal data provided in this form and any supporting document will be used by the Registrar of Patents ("the Registrar") for the "Purposes of Collection" set out in the Personal Information Collection Statement ("the PICS") at https://www.ipd.gov.hk/en/privacy-policy-statement/personal-information-collection-statement/index.html.
- b. In particular, YOU SHOULD BE AWARE THAT personal data collected by the Registrar may, in full or part, be made available online for public access and inspection; and
 - published or disclosed to the "Classes of Transferees" in or outside Hong Kong, China as set out in the PICS, including but not limited to the World Intellectual Property Organization and other intellectual property authorities/institutions/organizations which may subsequently make the relevant data available online for public access and inspection.
- **DO NOT** include in this form and any supporting document any irrelevant or unnecessary personal data (whether yours or others).

3. Use of other information:

- a. Other information, including those information relating to any business enterprise or entity, provided in this form and any supporting document will also be so used by the Registrar for the purposes as referred to in paragraph 2.a. above.
- b. Such information collected by the Registrar may, in full or part, also be so made available online, published or disclosed as set out in paragraph 2.b.(i) and (ii) above.
- <u>DO NOT</u> include in this form and any supporting document any information (whether yours or others) which is considered as confidential or commercially sensitive.

4. Submission of application/request/notice:

In person or by mail with the appropriate fee to the Registrar of Patents, 24/F, Wu Chung House, No. 213 Queen's Hong Road Wanchai, Kong, China. The fee schedule can be https://www.ipd.gov.hk/en/patents/forms-and-fees/index.html. Payment can be made in person by cash, or by sending a cheque/bank draft (in Hong Kong dollars which can be cleared in Hong Kong, China) made payable to THE GOVERNMENT OF THE HONG KONG SPECIAL ADMINISTRATIVE REGION.

4D	1 4
*Denotes mandatory fields	
01. Reference	
Filer's reference	
02. Application no./Patent no.	
Application no./Patent no. This form is for one patent application, patent or invention.	
03. *Full name of the applicant(s) or	proprietor(s)
(a) Name in English	
(a) Name in English	
(h) Nama in Ohinaa	
(b) Name in Chinese (if applicable)	
04. Details of the person(s) (other the intention to oppose, notice of oppose)	nan the applicant or proprietor) filing the notice of oposition or counter-statement
intention to oppose, notice of op	
If the person(s) filing this form is/are the	pposition or counter-statement
If the person(s) filing this form is/are the leave this part empty. (a) Name in English If the name is not in Roman letters or in Chinese, please include a transliteration	pposition or counter-statement
Intention to oppose, notice of op If the person(s) filing this form is/are the leave this part empty. (a) Name in English If the name is not in Roman letters or in Chinese, please include a transliteration in Roman letters. (b) Name in Chinese (if applicable)	pposition or counter-statement he applicant(s) or proprietor(s) mentioned in Part 03 above, please
If the person(s) filing this form is/are the leave this part empty. (a) Name in English If the name is not in Roman letters or in Chinese, please include a transliteration in Roman letters. (b) Name in Chinese	pposition or counter-statement
Intention to oppose, notice of op If the person(s) filing this form is/are the leave this part empty. (a) Name in English If the name is not in Roman letters or in Chinese, please include a transliteration in Roman letters. (b) Name in Chinese (if applicable)	pposition or counter-statement he applicant(s) or proprietor(s) mentioned in Part 03 above, please
Intention to oppose, notice of op If the person(s) filing this form is/are the leave this part empty. (a) Name in English If the name is not in Roman letters or in Chinese, please include a transliteration in Roman letters. (b) Name in Chinese (if applicable)	pposition or counter-statement he applicant(s) or proprietor(s) mentioned in Part 03 above, please Flat/Floor/Building
Intention to oppose, notice of op If the person(s) filing this form is/are the leave this part empty. (a) Name in English If the name is not in Roman letters or in Chinese, please include a transliteration in Roman letters. (b) Name in Chinese (if applicable)	pposition or counter-statement he applicant(s) or proprietor(s) mentioned in Part 03 above, please Flat/Floor/Building
Intention to oppose, notice of op If the person(s) filing this form is/are the leave this part empty. (a) Name in English If the name is not in Roman letters or in Chinese, please include a transliteration in Roman letters. (b) Name in Chinese (if applicable)	poposition or counter-statement he applicant(s) or proprietor(s) mentioned in Part 03 above, please Flat/Floor/Building Street/District

05. ^I	Notice of intention to oppose, n	otice ot o	pposition or counter-statement
Р	Please mark <u>one</u> box only.		
	his notice of intention to ppose is filed under:		section 41AA(1), Patents (General) Rules
	This notice of opposition relates to:		the surrender of a patent (section 40(2) and (3), Patents (General) Rules)
			the amendment of specification after grant (section 38B or 81Q, Patents (General) Rules)
			the correction of errors in a patent or patent application (section 48(4) and (5), Patents (General) Rules)
			the sample of micro-organism being available to an expert (paragraph 2D of Schedule 1, Patents (General) Rules)
			the reference to the Registrar to revoke a patent (section 41AAB(1) or 41AAC(1), Patents (General) Rules)
	his counter-statement is filed inder:		section 2C, Patents (General) Rules
			section 3(7), Patents (General) Rules
			section 7(3) and (4), Patents (General) Rules
			section 31G, Patents (General) Rules
			section 31L, Patents (General) Rules
			section 37(5), Patents (General) Rules
			section 38C or 81R, Patents (General) Rules
			section 40(4), Patents (General) Rules
			section 48(6A), Patents (General) Rules
06. S	supporting document(s)		
	Supporting document(s) filed vith this form		Statement setting out the grounds of opposition
	Please mark the appropriate box(es).		Counter-statement setting out the grounds of opposition or objection
			Others (please specify)

07. *Address for service

address used solely for mail forwarding

is not acceptable.

The address shall be treated as being All correspondence and/or document(g in substitution for any address for service previously filed. (s) will be sent to the address below.
*(a) Name	
*(b) Address You must provide details of an address for service in Hong Kong, China. Please	Flat/Floor/Building
note that a P.O. Box, a "care of" address or an address used solely for mail forwarding is not acceptable.	Street/District
	HONG KONG, CHINA
(c) Telephone no. In Hong Kong, China	
(d) Fax no. In Hong Kong, China	
08. Agent's details	
Go to Part 09 if you are NOT an agen	ıt.
	ct as an agent, please complete this part. The details provided in abstitution for any agent's details previously filed.
(a) Name	
(b) Address As an agent, you must provide the address of the premises in Hong Kong, China where you reside or carry on your	Flat/Floor/Building
business activities. Please note that a P.O. Box, a "care of" address or an	Street/District

HONG KONG, CHINA

09. *Declaration/Signature

Warning: It is an offence in law to furnish any false statement/information or make a false declaration in this form.

(If you are signing this form in the capacity of an agent) I/We declare that: I/We have been duly authorized to act as an agent as stated in Part 08. I/We reside or carry on business activities on the premises at the address in Hong Kong, China as specified in Part 08.

I/We confirm that I/we have read and understood the "Important notes" of this form.

*(a) Authorized signature		
*(b) Name of signatory		
*(c) Official capacity of signatory Examples: Authorized person, Director, Partner or Principal Officer of Applicant(s)/Proprietor(s)/the person(s) (other than the applicant or proprietor) filing this form/Agent; Applicant/Proprietor/the person(other than the applicant or proprietor) filing this form in person		
*(d) Date	DD-MM-YYYY	
(d) Date		
10. Attachment(s)		
Total number of attachment(s)		

For official use



Patents Form P6

Request for grant of a short-term patent

Patents Ordinance (Cap. 514)
Patents (General) Rules (Cap. 514C)

Important notes

1. General notes:

- a. This form is available in Chinese and English. Either Chinese or English can be used as the language of proceedings. Please complete this form in English unless otherwise stated. The specification must be in English.
- b. By submitting this form, you will be treated as having given consent to the Patents Registry and its service provider to copy or communicate all the information provided to any third party (in or outside Hong Kong, China) who assists or supports the Patents Registry in performing its functions under the Patents Ordinance, Cap. 514 and its subsidiary legislation.
- c. This form must be signed and dated.
- d. If there is not enough space for any part on this form, please continue on an additional sheet. Number each additional sheet and state the number of additional sheet(s) in Part 13(a).
- e. Please enquire through the following means:
 - E-mail: enquiry@ipd.gov.hk
 - Internet homepage address: www.ipd.gov.hk
- f. The Patents Ordinance, Cap 514 and Patents (General) Rules, Cap 514C can be viewed at www.ipd.gov.hk.

2. Use of personal data:

- a. Personal data provided in this form and any supporting document will be used by the Registrar of Patents ("the Registrar") for the "Purposes of Collection" set out in the Personal Information Collection Statement ("the PICS") at https://www.ipd.gov.hk/en/privacy-policy-statement/personal-information-collection-statement/index.html.
- b. In particular, YOU SHOULD BE AWARE THAT personal data collected by the Registrar may, in full or part, be—
 (i) made available online for public access and inspection; and
 - (ii) published or disclosed to the "Classes of Transferees" in or outside Hong Kong, China as set out in the PICS, including but not limited to the World Intellectual Property Organization and other intellectual property authorities/institutions/organizations which may subsequently make the relevant data available online for public access and inspection.
- c. <u>DO NOT</u> include in this form and any supporting document any irrelevant or unnecessary personal data (whether yours or others).

3. Use of other information:

- a. Other information, including those information relating to any business enterprise or entity, provided in this form and any supporting document will also be so used by the Registrar for the purposes as referred to in paragraph 2.a. above.
- b. Such information collected by the Registrar may, in full or part, also be so made available online, published or disclosed as set out in paragraph 2.b.(i) and (ii) above.
- c. <u>DO NOT</u> include in this form and any supporting document any information (whether yours or others) which is considered as confidential or commercially sensitive.

4. Submission of application/request/notice:

In person or by mail with the appropriate fee to the Registrar of Patents, 24/F, Wu Chung House, No. 213 Queen's Road East, Wanchai, Hong Kong, China. The fee schedule can be viewed at https://www.ipd.gov.hk/en/patents/forms-and-fees/index.html. Payment can be made in person by cash, or by sending a cheque/bank draft (in Hong Kong dollars which can be cleared in Hong Kong, China) made payable to THE GOVERNMENT OF THE HONG KONG SPECIAL ADMINISTRATIVE REGION.

5. Abbreviation:

The abbreviation "CNIPA" in Parts 06(e) and 13(j)(iii) & (iv) stands for the "China National Intellectual Property Administration" which was formerly known as the "State Intellectual Property Office, People's Republic of China".

P6-2

01. Reference	
Filer's reference	
02. Details of applicant(s)	
If there is more than one applicant, ple	ease provide details of <u>all</u> applicants.
(a) Name in English If your name is not in Roman letters or in Chinese, please include a transliteration in Roman letters.	
(b) Name in Chinese (if applicable)	
(c) Address	Flat/Floor/Building
	Street/District/City
	Country/Territory
(d) Applicant type Please mark <u>one</u> box only.	Individual Go to Part 03 Incorporated Go to Part 02(e) (and Part 02(f) if applicable) Unincorporated Go to Part 03
(e) Place of incorporation	
(f) State of incorporation	
03. Title of invention	
You must state the title of the invention	n in both English and Chinese.
(a) English	
(b) Chinese	

04. Number of independent claim(s)			P6-3
The number of independent claim(s) n	nust not ex	ceed two. (Section 113(1A)(b)(ii), Patents Ordinan	ce)
Number of independent claim(s) pro	ovided in t	ne specification	
05. Use of micro-organisms			
Go to Part 06 if the invention does NO	T require th	ne use of a micro-organism for its performance.	
If the invention requires the use of a box(es). (Section 73 and Schedule 1, F		anism for its performance, please mark the approprience () Rules)	opriate
(a) Is the micro-organism available to the public at the date of filing of the application; and	Yes	□No	
(b) Is the micro-organism described in the application or the specification of the patent in such a manner as to enable the invention to be performed by a person skilled in the art.	Yes	□ No	
(c) If you have marked "No" in both	boxes in	(a) and (b), please provide the following details	; :
(i) Name of the depositary institution			
(ii) Address of the depositary institution			
(iii) Date of deposit	DD-MM-YY	YY	
(iv) Accession no. of the deposit			
06. Details of international application	n n		
-		is NOT based on an international application.	
If the short-term patent application is details. (Section 125, Patents Ordinan		an international application, please provide the fol tion 78, Patents (General) Rules)	llowing
(a) International application no.			
(b) International filing date	DD-MM-YY	YY	
(c) International publication no.			

			P6-4
	(d) International publication date	DD-MM-YYYY	
	(e) Date of entry into the national phase in the People's Republic of China	DD-MM-YYYY	
	or		
	Date of issuance of an official notification by the CNIPA as prescribed under section 78 of the Patents (General) Rules	DD-MM-YYYY	
	(f) Application no. of the Chinese patent application (if known)		
07	. Statement of reference to an ea	rlier specified applic	ation
	Go to Part 08 if you do NOT make re	ference to an earlier spe	cified application.
			on 114(3)(c)(ii), Patents Ordinance is made, ovide the following details. (Sections 58(5)(i)
		patent application, are	s (if any) of the invention, which is the completely contained in the following
	subject of the short-term	patent application, are on: Earlier specified	completely contained in the following Earlier specified application
	subject of the short-term earlier specified application	patent application, are on:	completely contained in the following
	subject of the short-term earlier specified application	patent application, are on: Earlier specified	completely contained in the following Earlier specified application filing date
	subject of the short-term earlier specified application Country/Territory	patent application, are on: Earlier specified application no.	completely contained in the following Earlier specified application filing date
08	subject of the short-term earlier specified application Country/Territory Details of earlier application/rev	patent application, are on: Earlier specified application no.	Earlier specified application filing date
08	subject of the short-term earlier specified application Country/Territory	patent application, are on: Earlier specified application no.	Earlier specified application filing date
08	subject of the short-term earlier specified application Country/Territory Details of earlier application/rev Go to Part 09 if you do NOT claim the	patent application, are on: Earlier specified application no. /oked patent e filing date of an earlier ved from an earlier ap	Earlier specified application filing date
08	subject of the short-term earlier specified application Country/Territory Details of earlier application/rev Go to Part 09 if you do NOT claim the	patent application, are on: Earlier specified application no. /oked patent e filing date of an earlier ved from an earlier ap	Earlier specified application filing date DD-MM-YYYY application in Hong Kong, China, or derived application (section 116, Patents
08	subject of the short-term earlier specified application Country/Territory Details of earlier application/rev Go to Part 09 if you do NOT claim the lift the application is divided or derifrom a revoked patent, please provid (a) Type	patent application, are on: Earlier specified application no. /oked patent e filing date of an earlier ape the following details. Divisional Ordinance New app determinate	Earlier specified application filing date DD-MM-YYYY application in Hong Kong, China, or derived application (section 116, Patents
08	subject of the short-term earlier specified application Country/Territory Details of earlier application/rev Go to Part 09 if you do NOT claim the lift the application is divided or derifrom a revoked patent, please provid (a) Type	patent application, are on: Earlier specified application no. /oked patent e filing date of an earlier ape the following details. Divisional Ordinance New app determinate	Earlier specified application filing date DD-MM-YYYY application in Hong Kong, China, or derived application (section 116, Patents) lication filed on court order upon tion of right to patent after grant (section

09. Statement of priority claim

Go to Part 10 if you do NOT claim priority.

If a claim of priority under section 111, Patents Ordinance is made, please provide a statement of the following details. (Sections 58(5)(c), 69, Patents (General) Rules)

	Country/Territory	Priority application	n no.	Priority application filing date
1.				DD-MM-YYYY
2.				DD-MM-YYYY
3.				DD-MM-YYYY
10. Na	me(s) of inventor(s) (invent	tor must be individu	al not c	ompany)
If the	he applicant(s) is/are not the inv	ventor(s), a statement io apply for a short-term p	dentifying patent for	the inventor(s) and indicating how the the invention must be made on Form
	ne name of the inventor is not in ers.	Roman letters or in Ch	inese, ple	ease include a transliteration in Roman
	Name in Er	nglish	Na	ame in Chinese (if applicable)
1.				
2.				
3.				
4.				
5.				
11. Sta	atement of non-prejudicial o	disclosure		
Go	to <u>Part 12</u> if you do NOT claim	non-prejudicial disclosu	ıre.	
Ord evi	dinance, please provide a state	ement giving details re	elating to	sclosure under section 109, Patents such disclosure and provide written ance and sections 58(5)(f), 70, Patents
(a)	Statement			

			P6-6
(b) Name of the exhibition			
(c) Place of the exhibition			
(d) Opening date of the exhibition	DD-MM-YYYY		
(e) Date of first disclosure (if the first disclosure did not take place on the opening date of such exhibition)	DD-MM-YYYY		
12. Deferral of Grant			
Go to Part 13 if you do NOT request of	leferral of grant.		
If a request for deferral of grant under of such deferral.	section 119, Patents Ordinar	nce is required, please	enter the period
Deferral of grant up to (The period of deferral should not exceed 12 months)	DD-MM-YYYY		
13. List of documents			
Please enter the no. of sheets of attac	ched document(s), if any, in th	ne following box(es).	
(a) Additional sheet(s) attached to	this form		sheet(s)
(b) Description			sheet(s)
(c) Claim(s)			sheet(s)
(d) Drawing(s)			sheet(s)
(e) Abstract (in both English and C	hinese)		sheet(s)
(f) Priority document(s)			sheet(s)
(g) Translation of the priority doc application is not in one of the o			sheet(s)
(h) Search report			sheet(s)
(i) Translation of the search report languages)	(if not in one of the official		sheet(s)
(j) In the case of an international a	application, copy of:		
(i) the international applicat International Bureau	ion as published by the		sheet(s)

(ii) the international search re	port	Sneet(S)
(iii) translation of the interpublished by the CNIPA	rnational application as	sheet(s)
(iv) information as published the international application		sheet(s)
(k) Statement of inventorship on F	Form P6A	sheet(s)
(I) Sequence listing if the inventio amino acid sequences	n involves nucleotide and	sheet(s)
(Sequence listing may be filed in electron patent application is not filed by way of electrons.)		
(m) Others (please specify)		sheet(s)
14. Address for service		
All correspondence and/or document(s) will be sent to the address below	
(a) Name		
(a) Name		
(b) Address You must provide details of an address	Flat/Floor/Building	
for service in Hong Kong, China. Please note that a P.O. Box, a "care of" address or an address used solely for mail forwarding is not acceptable.	Street/District	
	HONG KONG, CHINA	
(c) Telephone no. In Hong Kong, China		
(d) Fax no. In Hong Kong, China		
15. Agent's details		
Go to <u>Part 16</u> if you are NOT an agen	t.	
Please complete this part if you have be for the purpose of this request.	een duly authorized to act as an agent on b	pehalf of the Applicant(s)
(a) Name		
(b) Address As an agent, you must provide the	Flat/Floor/Building	
address of the premises in Hong Kong, China where you reside or carry on your business activities. Please note that a P.O. Box, a "care of" address or an address used solely for mail	Street/District	
forwarding is <u>not acceptable</u> .	HONG KONG, CHINA	

16. Declaration/Signature

Warning: It is an offence in law to furnish any false statement/information or make a false declaration in this form.

(If you are signing this form in the capacity of an agent) I/We declare that:
I/We have been duly authorized to act as an agent as stated in Part 15.
I/We reside or carry on business activities on the premises at the address in Hong Kong, China as specified in Part 15.

I/We confirm that I/we have read and understood the "Important notes" of this form.

(a) Authorized signature

(b) Name of signatory

Examples: Authorized person, Director, Partner or Principal Officer of Applicant(s)/Agent; Applicant in person

(d) Date

香港特別行政區政府知識產權署
The Government of the Hong Kong Special Administrative Region
Intellectual Property Department

	UP
For official use	

Patents Form OP1

Request for grant of a standard patent (O)

Patents Ordinance (Cap. 514)
Patents (General) Rules (Cap. 514C)

Important notes

1. General notes:

- a. This form is available in Chinese and English. Either Chinese or English can be used as the language of proceedings. Please complete this form in English unless otherwise stated. The specification must be in English.
- b. By submitting this form, you will be treated as having given consent to the Patents Registry and its service provider to copy or communicate all the information provided to any third party (in or outside Hong Kong, China) who assists or supports the Patents Registry in performing its functions under the Patents Ordinance, Cap. 514 and its subsidiary legislation.
- c. This form must be signed and dated.
- d. If there is not enough space for any part on this form, please continue on an additional sheet. Number each additional sheet and state the number of additional sheet(s) in Part 11.
- e. Please enquire through the following means:
 - E-mail: enquiry@ipd.gov.hk
 - Internet homepage address: www.ipd.gov.hk
- f. The Patents Ordinance, Cap. 514 and Patents (General) Rules, Cap. 514C can be viewed at www.ipd.gov.hk.

2. Use of personal data:

- a. Personal data provided in this form and any supporting document will be used by the Registrar of Patents ("the Registrar") for the "Purposes of Collection" set out in the Personal Information Collection Statement ("the PICS") at https://www.ipd.gov.hk/en/privacy-policy-statement/personal-information-collection-statement/index.html.
- b. In particular, YOU SHOULD BE AWARE THAT personal data collected by the Registrar may, in full or part, be—
 - (i) made available online for public access and inspection; and
 - (ii) published or disclosed to the "Classes of Transferees" in or outside Hong Kong, China as set out in the PICS, including but not limited to the World Intellectual Property Organization and other intellectual property authorities/institutions/organizations which may subsequently make the relevant data available online for public access and inspection.
- c. <u>DO NOT</u> include in this form and any supporting document any irrelevant or unnecessary personal data (whether yours or others).

3. Use of other information:

- a. Other information, including those information relating to any business enterprise or entity provided in this form and any supporting document will also be so used by the Registrar for the purposes as referred to in paragraph 2.a. above.
- b. Such information collected by the Registrar may, in full or part, also be so made available online, published or disclosed as set out in paragraph 2.b.(i) and (ii) above.
- c. <u>DO NOT</u> include in this form and any supporting document any information (whether yours or others) which is considered as confidential or commercially sensitive.

4. Submission of application/request/notice:

In person or by mail with the appropriate fee to the Registrar of Patents, 24/F, Wu Chung House, No. 213 Queen's Road East, Wanchai, Hong Kong, China. The fee schedule can be viewed at https://www.ipd.gov.hk/en/patents/forms-and-fees/index.html. Payment can be made in person by cash, or by sending a cheque/bank draft (in Hong Kong dollars which can be cleared in Hong Kong, China) made payable to THE GOVERNMENT OF THE HONG KONG SPECIAL ADMINISTRATIVE REGION.

04	D-f	UP	1
U1.	Reference		
	Filer's reference		
02	Details of applicant(s)		
J_ .	If there is more than one applicant, ple	ease provide details of all applicants.	
			1
	(a) Name in English If your name is not in Roman letters		
	or in Chinese, please include a transliteration in Roman letters.		
	(h) Nama in Ohima		,]
	(b) Name in Chinese (if applicable)		
	(c) Address	Flat/Floor/Building	1
	(C) Address	riavi ioonbuilding	
		Street/District/City	
		Country/Territory	
	(d) Applicant type		J
	(d) Applicant type Please mark one box only.	Individual Go to Part 03	
		Incorporated Go to Part 02(e) (and Part 02(f) if applicable)	
		Unincorporated Go to Part 03	
	(e) Place of incorporation		1
	(e, 1 1000 c. 11100 portuno.)		
	(f) State of incorporation		1
03.	Title of invention		
	You must state the title of the invention	n in both English and Chinese.	
	(a) English		1
	(a) Liigiisii		

	(b) Chinese				
	(b) chinese				
04.	Use of micro-organisms				
	Go to Part 05 if the invention does NO	T requir	e the	e use of a micro-organism fo	r its performance.
	If the invention requires the use of a box(es). (Section 31ZW and Schedule		-	·	ease mark the appropriate
	(a) Is the micro-organism available to the public at the date of filing of the application; and	☐ Ye	es	□No	
	(b) Is the micro-organism described in the application or the specification of the patent in such a manner as to enable the invention to be performed by a person skilled in the art.	Ye	es	□No	
	(c) If you have marked "No" in both	ı boxes	in (a) and (b), please provide t	the following details:
	(i) Name of the depositary institution				
	(ii) Address of the depositary institution				
	(iii) Date of deposit	DD-MM	1-YYY	ΥΥ	
	(iv) Accession no. of the deposit				
05.	Statement of priority				
	Go to Part 06 if you do NOT claim prio	rity.			
	If a claim of priority under section 37 following details. (Sections 31C and 3	E, Pate			provide a statement of the
	Country/Territory		Р	riority application no.	Priority application
	1.				filing date DD-MM-YYYY
	2.				DD-MM-YYYY

				OP1
	3.			DD-MM-YYYY
	4.			DD-MM-YYYY
	5.			DD-MM-YYYY
06.	Statement of reference to an e	earlier spe	cified application	
	Go to Part 07 if you do NOT make	reference to	an earlier specified application	٦.
	If a reference to an earlier specific please provide a statement by ma 31W , Patents (General) Rules)			
		patent (O) a	I the drawings (if any) of the pplication, are completely co	
	Country/Territory		Earlier specified	Earlier specified
	Country/Territory		Earlier specified application no.	Earlier specified application filing date
	Country/Territory		-	application filing date
	Country/Territory		-	application filing date
07.	Country/Territory Details of earlier application/r	evoked pa	application no.	application filing date
07.		-	application no.	application filing date
07.	Details of earlier application/r	the filing dat	application no. tent e of an earlier application. n earlier application in Hong K	application filing date DD-MM-YYYY
07.	Details of earlier application/r Go to Part 08 if you do NOT claim? If the application is divided or der	the filing dat	application no. tent e of an earlier application. n earlier application in Hong K	application filing date DD-MM-YYYY
07.	Details of earlier application/r Go to Part 08 if you do NOT claim If the application is divided or der a revoked patent, please provide the (a) Type	the filing dat	application no. tent e of an earlier application. n earlier application in Hong K details. Divisional application Ordinance) New application filed o Registrar or court upon o	application filing date DD-MM-YYYY Cong, China, or derived from
07.	Details of earlier application/r Go to Part 08 if you do NOT claim If the application is divided or der a revoked patent, please provide the (a) Type	the filing dat	tent e of an earlier application. n earlier application in Hong K details. Divisional application Ordinance) New application filed o Registrar or court upon of of questions as to who r Patents Ordinance) New application filed	application filing date DD-MM-YYYY Cong, China, or derived from (section 37Z, Patents In an order made by the determination before grant

DD-MM-YYYY

(c) Earlier application filing date

08. Name(s) of inventor(s) (inventor must be individual not company)

09.

If the applicant(s) is not an inventor(s), a statement indicating how the applicant(s) becomes entitled to apply for a standard patent (O) for the invention must be made on Form OP1A. (Section 37L(3)(c), Patents Ordinance and section 31T, Patents (General) Rules)

If the name of the inventor is not in Roman letters or in Chinese, please include a transliteration in Roman letters.

	Name in Engli	ish	Name in Chinese (if applicable)
1.			
2.			
3.			
4.			
5.			
	n-prejudicial disclosure		
Go	to <u>Part 10</u> if you do NOT claim non	n-prejudicial disclo	sure.
(a)	Evident abuse of the invention		
	to in section 37B(2)(b)(i), Patent	s Ordinance, ple	prejudicial disclosure of an invention referred ase provide a statement to the effect that there ne box below, and written evidence in support
	Statement		
(b)	Disclosure at an official, or offic	cially recognized	, international exhibition
. ,	If the applicant is making a claim regarding non-prejudicial disclosure of an invention referred to in section 37B(2)(b)(ii), Patents Ordinance, please provide a statement of the following details, and prescribed written evidence in support of the statement referred to in section 31A, Patents (General) Rules.		
	Name of the exhibition		
	Place of the exhibition		

	Opening date of the exhibition	DD-MM-YYYY		
	Date of first disclosure (if the first disclosure did not take place on the opening date of such exhibition)	DD-MM-YYYY		
10. Ea	arly publication of application			
If se	the applicant requests early publication 31Z(1), Patents (General) Fordinance)			
	I/We request early publicat in section 31Z(1), Patents (in the prescribed time	e referred to
11. Lis	st of documents			
Pl	ease enter the no. of sheets of attac	hed document(s), if any, in th	ne following box(es).	
(a)) Description (not including sequ	ence listing)		sheet(s)
(b) Claim(s)			sheet(s)
(c)) Drawing(s)			sheet(s)
(d	Abstract (in both English and C Please indicate on the abstract drawings which should accomp published.	the figure(s) of the		sheet(s)
(e)	Priority document(s)			sheet(s)
(f)	Statement of inventorship on Fo	orm OP1A		sheet(s)
(g) Sequence listing if the inventior amino acid sequences	n involves nucleotide and		sheet(s)
	(Sequence listing may be filed in the standard patent (O) applicat electronic filing.)			
(h	Others (please specify)			sheet(s)
(i)	Total number of sheets			sheet(s)

12. Address for service	2. Address for service		
All correspondence and/or document(s) will be sent to the address below.			
(a) Name			
(b) Address You must provide details of an address for service in Hong Kong, China. Please note that a P.O. Box, a "care of" address or an address used solely for mail forwarding is not	Flat/Floor/Building Street/District		
<u>acceptable</u> .	HONG KONG, CHINA		
(c) Telephone no. In Hong Kong, China			
(d) Fax no. In Hong Kong, China			
13. Agent's details			
Go to <u>Part 14</u> if you are NOT an age	ent.		
Please complete this part if you have for the purpose of this request.	Please complete this part if you have been duly authorized to act as an agent on behalf of the applicant(s)		
(a) Name			
(b) Address As an agent, you must provide the address of the premises in Hong Kong, China where you reside or carry on your business activities. Please note	Flat/Floor/Building		
that a P.O. Box, a "care of" address or an address used solely for mail forwarding is not acceptable.	Street/District		
	HONG KONG, CHINA		

14. Declaration/Signature

Warning: It is an offence in law to furnish any false statement/information or make a false declaration in this form.

(If you are signing this form in the capacity of an agent) I/We declare that: I/We have been duly authorized to act as an agent as stated in Part 13. I/We reside or carry on business activities on the premises at the address in Hong Kong, China as specified in Part 13.

as specified in Part 13.	savines on the premises at the address in riong itong, omita
I/We confirm that I/we have read and u	understood the "Important notes" of this form.
(a) Authorized signature	
(b) Name of signatory	
(c) Official capacity of signatory Examples: Authorized person, Director, Partner or Principal Officer of Applicant(s)/Agent; Applicant in person	
(d) Date	DD-MM-YYYY